

## SPECIFICATION

## 1 TITLE OF THE INVENTION

DATA PROCESSING APPARATUS HAVING A FLASH  
MEMORY BUILT-IN WHICH IS REWRITABLE BY USE  
OF EXTERNAL DEVICE

## 5 CROSS-REFERENCE TO RELATED APPLICATIONS

This application is a continuation of  
application Serial No. 08/941,254, filed September 30,  
1997, which was a continuation of application Serial  
No. 08/524,107, filed August 21, 1995, now U. S. Patent  
10 No. 5,687,345, which was a continuation of application  
Serial No. 08/103,800, filed August 10, 1993, now  
abandoned, and which, in turn, was a continuation-in-  
part (CIP) of application Serial No. 08/031,877, filed  
March 16, 1993, now abandoned, the entire disclosures of  
15 which are incorporated herein by reference.

## BACKGROUND OF THE INVENTION

The present invention relates to a data  
processing apparatus having a built-in electrically  
20 rewritable nonvolatile flash memory. Further, the  
present invention relates to a technology which makes  
the built-in flash memory rewritable by use of an  
external device such as a PROM writer in the same way as  
a discrete flash memory, and to a technology which is  
25 useful when applied to a microcomputer, for example.

1 JP-A-161469 (laid-open on June 26, 1989 and  
corresponding to U.S. Application No. 116,607 filed on  
November 3, 1987) describes a microcomputer having an  
EPROM (Erasable and Programmable Read-Only Memories) or  
5 an EEPROM (Electrically Erasable and Programmable  
Read-Only Memories) as a programmable nonvolatile memory  
formed in a single semiconductor chip. Programs and  
data are held in such a nonvolatile memory disposed in  
the on-chip arrangement in the microcomputer. Since the  
10 EPROM needs ultraviolet rays to erase the stored data,  
rewrite cannot be effected unless the chip is removed  
from the applied system. Meanwhile, since the EEPROM  
can be electrically erased and written, the stored data  
can be rewritten with the EEPROM mounted onto the  
15 system. However, since memory cells constituting the  
EEPROM need select transistors besides the memory  
elements, such as MNOSs (Metal Nitride Oxide  
Semiconductors), the size of the memory cell becomes  
about 2.5 to 5 times as large as that of the memory cell  
20 of the EPROM. Therefore, a relatively large area of the  
chip is necessary for the nonvolatile flash memory  
portion.

JP-A-2-289997 (laid-open on November 29, 1990)  
describes a simultaneous erase type EEPROM. This  
25 simultaneous erase type EEPROM is synonymous to the  
flash memory disclosed in this specification. Data of  
the flash memory can be rewritten by implementing a

1 sequence of electrical erase and write operations, and  
the memory cell of this flash memory can be constituted  
by one transistor in the same way as the EPROM.  
Further, the flash memory has the function of  
5 simultaneously, electrically erasing all the memory  
cells as a bulk or, alternatively, one or more blocks of  
memory cells. Therefore, the stored data of the flash  
memory can be rewritten with the flash memory kept  
mounted on the system (in the on-board state). This  
10 simultaneous erase function can shorten the rewrite  
time, and also contributes to the reduction of the chip  
occupying area.

U.S. Patent 4,701,886 issued on October 20,  
1987 to Y. Sakakibara et al discloses a one-chip  
15 microcomputer having an EPROM. Data stored in that  
EPROM can be changed by externally supplying new data  
thereto from an EPROM writer.

U.S. Patent 4,807,114 issued on February 21,  
1989 to S. Itoh discloses a microcomputer which is  
20 programmable either externally or by its internal  
control function.

#### SUMMARY OF THE INVENTION

The present inventors have made  
25 investigations of a microcomputer having a flash  
memory mounted thereon. Though the microcomputer  
having a built-in flash memory can perform on-board

1 rewrite (namely, rewrite in a state in which the  
memory is mounted on a board), for an initial writing,  
write efficiency may be, in some cases, higher with a  
write device such as a PROM writer before the memory  
5 is mounted on a board, that is, before the memory is  
mounted onto a system (e.g., an automobile engine  
control system, a camera, a VTR, etc.) than with the  
on-board write technique, depending on a mode of use  
by a user. Thus, the present inventors have first  
10 found out the necessity for supporting the write  
function by a writer which is versatily utilized  
for write operations of both EPROMs and EEPROMs,  
such as a PROM writer, by connecting the writer  
through a socket adapter, to such a microcomputer  
15 with the built-in flash memory, too. Rewrite,  
namely, erase and write of the flash memory in this  
case requires more complicated control in comparison  
with the EPROMs and EEPROMs. To avoid over-erase (a  
phenomenon in which a threshold voltage of a memory  
20 cell transistor becomes so small and further becomes  
negative that normal readout is no longer possible)  
which is the problem inherent in the flash memory,  
particularly in the case of an erase operation, an  
erase technique which effects a pre-write operation  
25 for making the write level uniform before commencing  
with the erase operation or technique which gradually

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1 carries out an erase operation while effecting a verify  
function, becomes necessary. A control procedure for  
such a processing cannot be assigned to a versatile PROM  
writer as such, because a problem occurs in the  
5 processing, and it is not practical, either, to cope  
with this problem with a writer for exclusive use for  
the microcomputer having the built-in flash memory, such  
as the PROM writer.

10 It is an object of the present invention to  
provide a data processing apparatus having a built-in  
flash memory which is user-friendly in writing data  
therein by use of an external device such as a PROM  
writer, before the apparatus is mounted on a circuit  
board.

15 It is another object of the present invention  
to provide a data processing apparatus having a function  
of rewriting a built-in flash memory by use of an  
external device versatily utilized such as a PROM  
writer.

20 Further, it is another object of the present  
invention to provide a data processing apparatus, which  
minimizes the increase of a circuit scale to be  
additionally incorporated at this time for the purpose  
of data write by the external device.

25 The above and other objects and novel features  
of the present invention will become more apparent from  
the following description of the specification and the  
drawings.

1 Main aspects of the present invention will be explained briefly as follows.

(a) According to one aspect of the present invention, a data processing apparatus includes a  
5 central processing unit and an electrically rewritable nonvolatile flash memory both formed in a single semiconductor substrate, and is operable in an operation mode in which the built-in flash memory is rewritable in accordance with commands from an external  
10 device, and comprises command latch means which is writable from outside in the above-mentioned operation mode, command analysis (e.g., decoding) means for analyzing (e.g., decoding) predetermined commands latched in the command latch means, and control means for executing sequence control  
15 for a rewriting of the flash memory in accordance with a result of the analysis.

(b) During the rewrite operation of the flash memory by the external device, the built-in central processing unit (the central processing unit constituting the data processing apparatus) need not  
20 execute separate processing, and may be substantially at halt. In this instance, if the built-in central processing unit is used for executing the processings of the command analysis means and the  
25 control means described above, an exclusive circuit for rewriting such as the command analysis means and the control means can be reduced.

1           The external device versatilely utilized, such  
as an EPROM writer, has a function of applying a high  
voltage for rewrite to a nonvolatile memory device and a  
function of supplying an address for rewrite and data to  
5 a semiconductor device (LSI) coupled thereto and  
including the flash memory in accordance with a write  
signal and others. Such an external device supplies  
commands, data and addresses asynchronously with respect  
to the central processing unit built-in in the data  
10 processing apparatus. Thus, the data processing  
apparatus may further include, in the structure  
described in (a) above, flag means for indicating that a  
command is written in the command latch means, data  
latch means which is writable from outside when the  
15 flag means indicates a command latch state, and address  
latch means in which address data is writable from  
outside so as to prevent collision between a command and  
a data, that are written from the external device in  
mutually different cycles, on the latch means. Thereby,  
20 the central processing unit reads the command in the  
command latch means on the basis of the command latch  
state of the flag means.

(c)           If the control for the flag means is also  
assigned to the central processing unit, the central  
25 processing unit must always monitor the content of the  
command latch means using a bus cycle, which will be a  
wasteful operation. Accordingly, the data processing  
apparatus may further include, in the structure

1 described in (b) above, a command decoder for decoding  
the latch content of the command latch means and setting  
the flag means for the command latch state when decoding  
a predetermined command. Thereby, speed-up of control  
5 of the flag means will be possible.

(d) If the central processing unit analyzes all  
the latched commands, the operation designated by some  
of the commands may be too late in timing. An example  
is a read command for reading out data from the flash  
10 memory. To cope with this problem, the data processing  
apparatus may further include, in the structure described  
in (c) above, gate means which is provided in an internal  
bus and is capable of selecting the operation state where  
the command latch means, the data latch means and the  
15 address latch means are connected to the flash memory  
and to the central processing unit and another operation  
state where the command latch means, the data latch means  
and the address latch means are connected to the flash  
memory but are not connected to the central processing  
20 unit, and this gate means being controlled by a signal  
generated by the command decoder when it decodes a  
command other than the predetermined commands. Under  
the condition where such a gate means is open, direct  
read access can be made to the flash memory outside the  
25 data processing apparatus. The read command may be the  
command other than the predetermined commands described  
above. With this structure, the flash memory built-in  
in the data processing apparatus is equivalent, as



1 seen from the external device such as a PROM writer, to  
a discrete flash memory (LSI device) in respect of  
rewrite and read operations.

(e) A procedure control program for rewriting the  
5 flash memory, which the central processing unit should  
execute, is stored in advance in the flash memory, and  
this program is transferred to a RAM in the data  
processing apparatus in response to setting of the  
rewrite operation mode by the external device. The  
10 program transferred to the RAM can be executed by the  
central processing unit.

(f) The quantity of the data to be stored in the  
flash memory is different depending on the usage of the  
data or on the kind of the data such as a program, a  
15 data table, control data, etc. When this fact is taken  
into consideration, it is better to allocate a plurality  
of kinds of memory blocks having mutually different  
memory capacities, as a simultaneously erasable unit in  
the flash memory, in order to eliminate wasteful write  
20 operations caused by simultaneous erasure of all memory  
blocks of the built-in flash memory for local or partial  
rewrite of the data held by the built-in flash memory  
after the data processing apparatus having the flash  
memory has been mounted onto the system (circuit board)  
25 to thereby improve rewrite efficiency.

According to the above-described structures,  
since the rewrite sequence is accomplished by built-in  
circuits of the data processing apparatus having the

1 built-in flash memory, in accordance with commands given  
asynchronously from the external device, the external  
device has only to apply the commands to the data  
processing apparatus before it gives the apparatus data  
5 and address data, in the same way as it gives the data.  
And, data write in the built-in flash memory of the data pro-  
cessing apparatus can be effected by coupling (electrically  
connecting) the flash memory with the external device versa-  
tilely used such as a PROM writer, through a socket adapter.

10 The built-in central processing unit of  
the data processing apparatus controls the rewrite  
sequence designated by the commands, eliminates the  
necessity of exclusive circuits for the rewrite sequence  
control or reduces the number of such circuits, and  
15 accomplishes the reduction of the chip area of the data  
processing apparatus. Further, the control sequence for  
rewrite can be changed by modifying software that are  
to be executed by the central processing unit, and this  
makes it possible to set conditions such as a write time  
20 in a manner which matches with characteristics of the  
memory devices that constitute the flash memory.

#### BRIEF DESCRIPTION OF THE DRAWINGS

Figs. 1A and 1B are diagrams for explaining a  
structure and the principle of operation of a flash  
25 memory.

Fig. 2 is an explanatory view showing the  
structural principle of the flash memory for a memory

1 cell array.

Fig. 3 is an exemplary block circuit diagram of a flash memory in which the memory capacity of simultaneously erasable memory blocks is made mutually different.

Fig. 4 is a functional block diagram of a microcomputer having a built-in flash memory according to a first embodiment, in which a rewrite processing of the built-in flash memory is executed by a PROM writer.

Fig. 5 is a functional block diagram of a microcomputer having a built-in flash memory according to a second embodiment, in which a rewrite processing of the built-in flash memory is executed by a PROM writer.

Figs. 6A to 6C are timing charts showing an example of command write by a PROM writer.

Fig. 7 is a timing chart showing an example of a data write cycle for a flash memory by CPU control.

Fig. 8 is a block diagram showing details of a structure of a microcomputer corresponding to the microcomputer shown in Fig. 5.

Fig. 9 is a plan view showing the microcomputer shown in Fig. 8 in a packaged state.

Fig. 10 is an overall block diagram of the flash memory built-in in the microcomputer shown in Fig. 8.

Fig. 11 is an explanatory view showing an example of the mode of division of a memory block.

Figs. 12A to 12C are explanatory views showing

1 examples of a control register and an erase block  
designation register.

Fig. 13 is a block diagram showing details of  
hardware to cope with a PROM writer rewrite mode by a  
5 command system in the microcomputer shown in Fig. 8.

Fig. 14 is an explanatory view showing a  
control form of a command flag, a data flag and bus  
switches.

Figs. 15A and 15B show an exemplary detailed  
10 flowchart of a flash memory write control procedure with  
the microcomputer in an on-board state.

Figs. 16A and 16B show an exemplary detailed  
flowchart of a flash memory erase control procedure with  
the computer in an on-board state.

15 Fig. 17 is an explanatory view showing  
altogether states of flags CF and DF during the write  
operation by the PROM writer and the operation of a CPU.

Fig. 18 is an explanatory view showing  
altogether states of the flags at the time of write  
20 verify by the PROM writer and the operation of the CPU.

Figs. 19A and 19B are explanatory views  
showing altogether states of the flags at the time of  
reset by the PROM writer and the operation of the CPU.

Figs. 20A and 20B show an exemplary flowchart  
25 of the operation of the PROM writer at the time of data  
write by the command system.

1 Figs. 21A and 21B show an exemplary flowchart  
of the operation of the PROM writer at the time of erase  
by the command system.

Fig. 22 is a main flowchart showing the  
5 processing of the CPU for the command given from the  
PROM writer.

Figs. 23A and 23B are flowcharts showing  
processing routine of Erase and a processing routine of  
Erase Verify shown in Fig. 22.

10 Fig. 24 is a flowchart showing a processing  
routine of Auto Erase shown in Fig. 22.

Figs. 25A and 25B are flowcharts showing a  
processing routine of Program and a processing routine  
of Program Verify shown in Fig. 22.

## 15 DESCRIPTION OF PREFERRED EMBODIMENTS

Embodiments of the present invention will be  
described in the order of the items listed below.

- [1] Principle of operation of a flash memory
- [2] Division into a plurality of memory blocks having  
20 mutually different storage capacities
- [3] Principle of command system data write in a flash  
memory by PROM writer
- [4] Microcomputer
- [5] Built-in flash memory
- 25 [6] Hardware adapted to command system
- [7] Command specification of data write and others in  
a flash memory by PROM writer

- 1 [8] Data write in a flash memory in on-board state  
[9] Data write operation by command system  
[10] Operation of PROM writer for data write by  
command system  
5 [11] Operation of CPU for data write by command system  
[12] Compatibility between a flash memory built-in in  
a data processing apparatus and a discrete flash  
memory LSI in terms of write specification, as  
seen from PROM writer

- 10 [1] Principle of operation of a flash memory

Figs. 1A and 1B illustrate a structure and the principle of operation of a flash memory. A memory cell typically depicted in Fig. 1A comprises an insulated gate field effect transistor having a two-layered gate structure. In the drawing, reference numeral 1 denotes a P type silicon substrate, reference numeral 2 denotes a P type semiconductor region formed in the silicon substrate 1, and reference numerals 3 and 4 denote N type semiconductor regions. Reference numeral 5 denotes a floating gate formed on the P silicon substrate 1 through a thin oxide film 6 (10 nm-thick, for example) as a tunnel insulating film, and reference numeral 7 denotes a control gate formed on the floating gate 5 through the oxide film 8. A source is constituted by region 4 and a drain by region 3. Data stored in this memory cell is held substantially as a change of

1 a threshold voltage by a transistor. Hereinafter, the  
description will be given on the case where the  
transistor for storing data (hereinafter also referred  
to as the "memory cell transistor") in the memory cell  
5 is of the N channel type unless specifically described  
otherwise.

The data write operation in the memory cell is  
accomplished, for example, by applying a high voltage to  
the control gate 7 and the drain and injecting electrons  
10 from the drain side to the floating gate by avalanche  
injection. Due to this write operation, the threshold  
voltage of the memory transistor, as viewed from its  
control gate 7, becomes higher than that of the memory  
transistor under an erase state, to which the write  
15 operation is not executed, as shown in Fig. 1B.

On the other hand, the erase operation is  
accomplished, for example, by applying a high voltage to  
the source and extracting the electrons from the  
floating gate 5 to the source side by the tunnel  
20 phenomenon. Due to this erase operation, the threshold  
voltage of the memory transistor as viewed from its  
control gate 7 is lowered as shown in Fig. 1B. In Fig.  
1B, the threshold value of the memory cell transistor is  
set for a positive voltage level in both of the write  
25 and erase states. In other words, the threshold voltage  
under the write state is set to be higher than the word  
line selection level applied from a word line to the  
control gate 7 and the threshold voltage under the erase

1 state is set to be lower. Since both of the threshold  
voltages and the word line selection level have such a  
relationship, the memory cell can be constituted by one  
transistor without using a select transistor in  
5 combination. To electrically erase the stored data, the  
electrons accumulated in the floating gate 5 are  
extracted to the source electrode. Since erase of the  
stored data is thus effected, a greater quantity of  
electrons than the quantity of the electrons injected  
10 into the floating gate 5 during the write operation are  
extracted if the erase operation is continued for a  
relatively long time. Accordingly, if over-erase is  
carried out such as when the electrical erase is  
continued for a relatively long time, the threshold  
15 voltage of the memory cell transistor changes to a  
negative level, for example, and there occurs the  
problem that the memory cell transistor is selected at a  
non-selection level of the word line, too.  
Incidentally, the write operation can be effected also  
20 by utilizing the tunnel current in the same way as the  
erase operation.

In the read operation, the voltages applied to  
the drain 3 and to the control gate 7 are limited to  
relatively low values so that a weak write is not made  
25 in the memory cell or in other words, undesired  
injection of carriers is not made in the floating gate  
5. For example, a low voltage of above 1 V is applied  
to the drain and a low voltage of about 5 V is applied



1 to the control gate 7. The logic values "0" and "1" of  
the data stored in the memory cell can be discriminated  
by detecting the magnitude of the channel current  
flowing through the memory cell due to these applied  
5 voltages.

Fig. 2 shows the structural principle of a  
memory cell array using the memory cell transistors  
described above. This drawing, for purposes of the  
present discussion, illustrates a matrix arrangement of  
10 only four memory cell transistors Q1 to Q4. Among the  
memory cells arranged in matrix in X and Y directions,  
the control gates (selection gates of the memory cells)  
of the memory cell transistors Q1, Q2, (Q3, Q4) arranged  
on the same row are connected to a corresponding word  
15 line WL1 (WL2) and the drain regions (input/output nodes  
of the memory cells) of the memory cell transistors  
Q1, Q3 (Q2, Q4) disposed on the same column are  
connected to a corresponding data line DL1 (DL2). The  
source regions of the memory cell transistors Q1, Q3  
20 (Q2, Q4) are connected to a source line SL1 (SL2).

Table 1 shows an example of voltage conditions  
for the erase and write operations for the memory cells.

Table 1

OPERATION MODE	MEMORY CELL	SELECT/NON-SELECT	SOURCE	DRAIN	GATE
WRITE	Q1	SELECT	0 V	6 V	12 V
	Q2	NON-SELECT	0 V	0 V	12 V
	Q3	NON-SELECT	0 V	6 V	0 V
	Q4	NON-SELECT	0 V	0 V	0 V
ERASE (1)	Q1, Q3	SELECT	12 V	0 V	0 V
	Q2, Q4	NON-SELECT	0 V	0 V	0V
ERASE (2)	Q1, Q2	SELECT	5 V	0 V	-10 V
	Q3, Q4	NON-SELECT	5 V	0 V	0 V

ERASE (1): POSITIVE VOLTAGE SYSTEM ERASE OPERATION

ERASE (2): NEGATIVE VOLTAGE SYSTEM ERASE OPERATION

1 In Table 1, the term "memory cell" means a memory cell transistor and the term "gate" means the "control gate" of the memory cell transistor as the selection gate. In Table 1, the erase operation by a negative voltage system is accomplished by applying a negative voltage of -10 V, for example, so as to generate a high electric field necessary for erase. As can be understood clearly from Table 1, simultaneous erase can be made in the erase operation of a positive voltage system for those memory cells at least the sources of which are connected in common. According to the structure shown in Fig. 2, therefore, the four memory cells Q1 to Q4 can be simultaneously erased if the source lines SL1 and SL2 are connected. In this

1 case, the size of the memory block can be set for an  
arbitrary size by changing the number of memory cell  
transistors connected to the same source line. Besides  
the case using the data line as a unit as typically  
5 shown in Fig. 2 (the case where the common source line  
is extended in the direction of the data line), a source  
line division system includes also a case using the word  
line as a unit (the case where the common source line is  
extended in the direction of the word line). On the  
10 other hand, simultaneous erase can be made for those  
memory cells the control gates of which are connected in  
common, in the erase operation of the negative voltage  
system.

[2] Division into a plurality of memory blocks having  
15 mutually different memory capacities

Fig. 3 is a block circuit diagram showing an  
example of a flash memory including memory blocks which  
are simultaneously erasable and have mutually different  
memory capacities.

20 The flash memory FMRY1 shown in Fig. 3 has 8-  
bits data input/output terminals D0 to D7, and is  
equipped with memory cell arrays ARY0 to ARY7 for each  
data input/output terminal. Each of the memory cell  
arrays ARY0 to ARY7 is divided into a memory block LMB  
25 having a relatively large memory capacity and a memory  
block SMB having a relatively small memory capacity,  
though this arrangement is not particularly limitative.  
The diagram particularly illustrates details of the

1 memory cell array ARY0 as a typical example, but the  
other memory cell arrays ARY1 to ARY7, too, have a  
similar structure.

In each of the memory arrays ARY0 to ARY7,  
5 memory cells MC each comprising an insulated gate field  
effect transistor having the two-layered gate structure  
explained with reference to Figs. 1A and 1B are arranged  
in matrix. In Fig. 3, symbols WL0 to WLn represent word  
lines which are in common to all the memory cell arrays  
10 ARY0 to ARY7. The control gates of the memory cells  
disposed on the same row are connected to the  
corresponding word line. In each of the memory arrays  
ARY0 to ARY7, the drain regions (first main electrodes)  
of the memory cells MC disposed on the same column are  
15 connected to the corresponding data line DL0 to DL7.  
The source regions (second main electrodes) of the  
memory cells MC constituting the memory block SMB are  
connected in common to the source line SL1, and the  
source regions of the memory cells MC constituting the  
20 memory block LMB are connected in common to the source  
line SL2.

A high voltage  $V_{pp}$  utilized for erase is  
supplied from voltage output circuits VOUT1, VOUT2 to  
the source lines SL1, SL2 described above. The  
25 operation of the voltage output circuits VOUT1, VOUT2 is  
selected in accordance with the value of bits B1, B2 of  
an erase block designation register. For example, when  
"1" is set for the bit B1 of the erase block designation

00423085 004098  
000480 5802260

1 register, only the small memory blocks SMB of the memory  
cell arrays ARY0 to ARY7 can be simultaneously erased.  
When "1" is set for the bit B2 of the erase block  
designation register, only the large memory blocks LMB  
5 of the memory cell arrays ARY0 to ARY7 can be  
simultaneously erased. When "1" is set for both of the  
bits B1 and B2, the flash memory can be simultaneously  
erased as a whole.

#### Selection of the word lines WL0 to WLn

10 described above is effected when an X address decoder  
XADEC decodes an X address signal AX fetched through an  
X address buffer XABUFF and an X address latch XALAT. A  
word driver WDRV drives the word line on the basis of a  
select signal outputted from the X address decoder  
15 XADEC. In the data read operation, the word driver WDRV  
is operated using a voltage Vcc such as 5 V supplied  
from a voltage select circuit VSEL and a ground  
potential such as 0 V as the power source, drives the  
to-be-selected word line to the select level by the  
20 voltage Vcc and keeps the word line, which is not to be  
selected, at a non-select level such as 0 V. In the  
data write operation, the word driver WDRV is operated  
using a voltage Vpp such as 12 V supplied from a voltage  
selection circuit VSEL and the ground potential such as  
25 0 V as the power source, and drives the to-be-selected  
word line to a high voltage level for writing such as 12  
V. In the data erase operation, the output of the word  
driver WDRV is set to a low voltage level such as 0 V.

1 In each of the memory cell arrays ARY0 to ARY7, the data lines DL0 to DL7 are connected in common to the common data line CD through Y select switches YS0 to YS7.

Switch control of the Y select switches YS0 to YS7 is  
5 effected when the Y address decoder YADEC decodes a Y address signal AY fetched through the Y address buffer YABUFF and the Y address latch YALAT. The output select signal of the Y address decoder YADEC is supplied in common to all the memory cell arrays ARY0 to ARY7.

10 Accordingly, when any one of the output select signals of the Y address decoder YADEC is set for the select level, the common data line CD is connected to one data line in each of the memory cell arrays ARY0 to ARY7.

The data read out from the memory cell MC to  
15 the common data line CD is applied to a sense amplifier SA through the select switch RS, is amplified by this sense amplifier, and is then outputted outside from a data output buffer DOB through a data output latch DOL. The select switch RS is set for the select level in  
20 synchronism with the read operation.

The write data supplied from outside is held by a data input latch DIL through a data input buffer DIB. When the data latched by the data input latch DIL is "0", the write circuit WR supplies a high voltage for  
25 write to the common data line CD through the select switch WS. This high voltage for write is supplied through the data line selected by the Y address signal AY to the drain of the memory cell receiving the high

1 voltage at the control gate thereof by the X address  
signal AX. In this way, this memory cell is written.  
The select switch WS is set for the select level in  
synchronism with the write operation.

5 Various timings for write/erase and select  
control of the voltage are generated by a write/erase  
control circuit WECONT.

There is a case where the data quantity to be  
stored in the flash memory FMRY1 is different depending  
10 on the usage of data and on the kinds of the data such  
as a program, a data table, a control data, and so  
forth. In consideration of such a case, a plurality of  
memory blocks SMB, LMB having mutually different storage  
capacities are provided as a simultaneously erasable  
15 unit in the flash memory. According to such a  
construction, any waste of the write operation  
undesirably caused by simultaneous erase of all the  
memory blocks for local or partial rewrite of the stored  
data of the flash memory built-in in the microcomputer  
20 after the microcomputer has been mounted onto a circuit  
board, can be eliminated to improve the write  
efficiency.

[3] Principle of data write in a flash memory by  
command system by PROM writer

25 Fig. 4 is a functional block diagram when the  
built-in flash memory of the microcomputer MCU1 (which  
may be formed in a single semiconductor substrate)  
having the flash memory FMR2, according to the first

1 embodiment of the present invention, is subjected to a  
rewrite processing by a PROM writer.

Fig. 4 illustrates the central processing unit  
(hereinafter also referred to merely as "CPU") 10, the  
5 flash memory FMRY2 and the control circuit 20 as  
exemplary circuit modules sharing the internal bus BUS.  
This microcomputer MCU1 has a write operation mode by  
use of the PROM writer 30. For example, when the  
microcomputer MCU1 is connected to predetermined  
10 terminals of the PROM writer 30 through a socket  
adapter, not shown, the mode setting terminal, not  
shown, of the microcomputer MCU1 is compulsively set for  
a predetermined level, so that the operation mode of the  
microcomputer MCU1 is set for the write mode by the PROM  
15 writer 30 (ROM writer write mode operation). In such an  
operation mode, the CPU 10 is cut off from the internal  
bus BUS through a bus switch, not shown. In a state  
where the write operation mode is set by the PROM writer  
30, the control circuit 20 includes command latch 21  
20 which is made writable from the PROM writer 30 and  
serves to latch a command supplied from the PROM writer,  
command analyzer 22 for analyzing (i.e., decoding)  
the command latched in the command latch, and sequence  
controller 23 for executing sequence control for  
25 rewriting of the flash memory in accordance with the  
analyzed content. The PROM writer 30 supplies  
predetermined commands such as erase, erase verify,  
program (write), program verify, etc., and suc-  
cessively supplies necessary data and address data to



1 the control circuit 20. The command supplied from the  
PROM writer 30 is interpreted by the command analyzer 22  
and the sequence controller 23 applies to the flash memory  
FMRY2 a control signal for a write operation utilizing the  
5 necessary data and address data in accordance with the  
interpretation by the analyzer 22.

As has been described above, the rewrite  
(erase and write) sequence in accordance with commands  
given from the PROM writer 30 can be accomplished by the  
10 control circuit 20 included in the microcomputer MCU1 by  
having the PROM writer 30 only to supply commands, before  
supply of data and address information, to the  
microcomputer MCU1 in the same way as the PROM writer 30  
supplies the data thereto. Accordingly, by connecting  
15 microcomputer MCU1 to the PROM writer 30 which is  
generally utilized, through a socket adapter, data can  
be written to the flash memory FMRY2 built-in in the  
microcomputer. In this construction, the microcomputer  
MCU1 in which the write mode by the PROM writer 30 is  
20 set can be regarded as identical with a discrete flash  
memory chip by the PROM writer 30.

Fig. 5 shows a functional block diagram of a  
microcomputer MCU2 (which may be formed in a single  
semiconductor substrate) having the flash memory FMRY2  
25 built-in according to a second embodiment, in which a  
rewrite processing is executed for the built-in flash  
memory MRY2 by the PROM writer 30.

1           The microcomputer MCU2 shown in Fig. 5  
eliminates the exclusive circuits for rewrite, such as  
the command analyzer 22 and the sequence controller 23,  
by allowing the built-in CPU 10 to execute the command  
5 analysis and the sequence control without the control  
circuit 20. In Fig. 5, since the CPU 10 is cut off from  
the internal bus BUS during the write mode by the PROM  
writer 30, there is no necessity for the built-in CPU 10  
to execute a different processing during the rewrite  
10 operation of the flash memory FMRY2 by the PROM writer  
30, and therefore, it may be highly possible that the  
CPU 10 is at halt or dormant, due to the disconnection  
from the internal bus. The structure shown in Fig. 5  
efficiently utilizes such built-in CPU 10.

15           Fig. 5 typically shows the CPU 10, the flash  
memory FMRY2 and the command latches 21a to 21c as the  
circuit modules sharing the internal bus BUS. This  
microcomputer MCU2 has a write mode by the PROM writer  
30. For example, when the microcomputer MCU2 is  
20 connected to the predetermined terminals of the PROM  
writer 30 through the socket adapter, not shown, the  
mode setting terminal of the microcomputer MCU2, not  
shown, is compulsively set for the predetermined level,  
and the write mode by the PROM writer 30 is set. The  
25 PROM writer 30 is disconnected from the internal bus BUS  
so as not to directly supply the data and the address  
information to the internal bus so that the supplied  
information do not conflict with the internal bus access

1 by the CPU 10; however, the construction is not particu-  
larly limited thereto. The command, data and the address  
information are written in the command latch 21a, data  
latch 21b and the address latch 21c, respectively. The  
5 CPU 10 realizes, in the write operation mode by the PROM  
writer 30, a function of the command analyzer 22 for  
analyzing the command written from the PROM writer 30  
and a function of the sequence controller 23 for  
executing the sequence control for rewriting the flash  
10 memory FMRY2 in accordance with the analyzed content, as  
well as a control program for the functions. The PROM  
writer 30 supplies to the latches 21a to 21c  
predetermined commands such as erase, erase verify,  
program (write), program verify, etc, and successively  
15 supplies the necessary data information and address  
information. The command supplied from the PROM writer  
30 is interpreted by the CPU 10, and the CPU 10 sends a  
control signal for the write operation to the flash  
memory FMRY2 by utilizing the necessary data information  
20 and address information written in the address latch 21b  
and data latch 21c.

Figs. 6A to 6C show an example of a command  
write timing by the PROM writer 30. In Fig. 6A, the  
cycle labeled "command write cycle" is the write cycle  
25 by the PROM writer 30 into the microcomputer MCU2.  
First, the command is written in the command latch 21  
and then, the data information and the address  
information are written in the data latch 21c and the

28

1 address latch 21b, respectively, whenever necessary. In  
Fig. 6A, the cycle labeled "write cycle" is the data  
information write cycle into the flash memory which is  
executed under the CPU control in accordance with the  
5 content written by the PROM writer 30.

Fig. 7 shows an exemplary timing of the data  
write cycle into the flash memory by the CPU control.  
This write cycle includes a cycle of the command  
analysis by the CPU 10, a write cycle executed for  
10 actual write in the flash memory in accordance with the  
command analysis result and a cycle of post-processing.

The microcomputer MCU2 according to the second  
embodiment, too, is capable of writing data in the flash  
memory FMRY2 built-in in the microcomputer by connecting  
15 the PROM writer 30, which is generally utilized, through  
the socket adapter in the same way as in the first  
embodiment. Further, since the CPU 10 controls the  
sequence for rewrite designated by the command, an  
exclusive circuit or circuits for this control can be  
20 eliminated or reduced, and the chip area of the  
microcomputer MCU2 can also be reduced. Because the  
control sequence for rewrite is changeable by the  
software to be executed by the CPU 10, a condition such  
as the write time can be set in accordance with the  
25 characteristics of the memory cell transistors  
constituting the flash memory FMRY2. A comparison  
between the first embodiment and the second embodiment  
show differences such as listed in Table 2.

Table 2

ITEM	2ND EMBODIMENT (CPU CONTROL)	1ST EMBODIMENT (HARDWARE CONTROL)
SCALE OF CONTROL CIRCUIT	300 Trs.	3,200 Trs.
CHANGES OF COMMAND SPECIFICATION	SOFTWARE CHANGES	MASK CHANGES
CHANGES OF WRITE/ERASE CONDITIONS	SOFTWARE CHANGES	MASK CHANGES

1 [4] Microcomputer

Fig. 8 is a block diagram showing details of a microcomputer MCU3 corresponding to the microcomputer shown in Fig 5.

5 The microcomputer MCU3 shown in Fig. 8 includes the CPU 10, the flash memory FMRY2, a serial communication interface SCI, the control circuit CONT, a random access memory RAM, a 16-bit integrated timer/pulse unit IPU, a watch-dog timer WDTMR, ports 10 PORT1 to PORT12, a clock generator CPG, an interrupt controller IRCONT, an analog/digital converter ADC and a wait state controller WSCONT. These circuit modules are formed in a single semiconductor substrate such as a silicon substrate by a known semiconductor 15 integrated circuit fabrication technique, although not to be considered as being limited thereto.

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1           The CPU 10, the flash memory FMRY2, the random  
access memory RAM and the 16-bit integrated timer/pulse  
unit IPU are connected to the address bus ABUS, to a low  
order data bus LDBUS (e.g. 8 bits) and to a high order  
5 data bus HDBUS (e.g. 8 bits). The serial communication  
interface SCI, the watch-dog timer WDTMR, the interrupt  
controller IRCONT, the analog/digital converter ADC, the  
wait state controller WSCONT and the ports PORT1 to  
PORT12 are connected to the address bus ABUS and to the  
10 high order data bus HDBUS.

          In Fig. 8, Vpp denotes a high voltage for  
rewriting the flash memory FMRY2. EXTAL and XTAL denote  
signals applied from an oscillator, which is externally  
connected to the chip of the microcomputer MCU3 and is  
15 not shown in the drawing, to the clock generator CPG  
described above.  $\phi$  denotes a sync clock signal  
outputted outside from the clock generator CPG. RES\*  
(symbol \* represents that the signal with this asterisk  
is a low enable signal) is a reset signal, and STBY\*  
20 denotes a standby signal, and is supplied to the CPU 10  
and to other circuit blocks. NMI denotes a non-maskable  
interrupt signal, and applies a non-maskable interrupt  
to the interrupt controller IRCONT. Other interrupt  
signals not shown are given to the interrupt controller  
25 IRCONT through the ports PORT8 and PORT 9. AS\* denotes  
an address strobe signal representing effectiveness of  
the address signal outputted outside, RD\* denotes a read  
signal notifying to the outside that the operation cycle



1 the data BD0 to BD15 by the microcomputer MCU3 in order  
to make an access to the outside, though this  
arrangement is not particularly limitative. The ports  
PORT3 to PORT5 are allocated to the output operation of  
5 the address signals BA0 to BA19 at this time, though  
this arrangement is not particularly limitative, either.

On the other hand, when the PROM writer write  
mode is set in the microcomputer MCU, the ports PORT2 to  
PORT5 and PORT8 are allocated to the connection with the  
10 PROM writer 30 for the rewrite control of the flash  
memory FMRY2 at this time, though this arrangement is  
not particularly limitative. In other words, the port  
PORT2 is allocated to command write and to input/output  
of data ED0 to ED7 for data write and write verify, and  
15 the ports PORT3 to PORT5 and PORT8 are allocated to  
input of the address signal EA0 to EA16 and to input of  
the access control signals CE\* (chip enable signal),  
OE\* (output enable signal) and WE\* (write enable  
signal). The chip enable signal CE\* is a chip select  
20 signal from the PROM writer 30, the output enable signal  
OE\* is an instruction signal of the output operation for  
the microcomputer MCU3, and the write enable signal WE\*  
is an instruction signal of the write operation for the  
microcomputer MCU3. By the way, the input terminal of  
25 the signal NMI is allocated to the input of one bit EA9  
among the address signals EA0 to EA16. The external  
terminals of the ports allocated in this way and other  
necessary external terminals such as the terminal of the





1 ARY, the control gate of each memory cell is connected  
to the corresponding word line, the drain region of the  
memory cell is connected to the corresponding data line  
and the source region of the memory cell is connected to  
5 the common source line for each memory block in the same  
way as in the structure which has been explained with  
reference to Fig. 3. However, the mode of division of  
the memory cell blocks may be different from that shown  
in Fig. 3. As shown in Fig. 11, for example, it is  
10 divided into seven large memory blocks (large blocks)  
LMB0 to LMB6 having relatively large storage capacities  
and eight small memory blocks (small blocks) SMB0 to  
SMB7 having relatively small storage capacities. Each  
large memory block is utilized for a program storage  
15 region or a large capacity data storage region. Each  
small memory block is utilized for a small capacity data  
storage region.

In Fig. 10, AIL denotes a latch circuit for  
the address signals PAB0 to PAB15. The address signals  
20 PAB0 to PAB15 correspond to the output address signals  
delivered to the address bus ABUS from the CPU 10, and  
also correspond to the output address signals EA0 to  
EA15 of the PROM writer 30 in the PROM writer write  
mode, respectively. XADEC denotes the X address decoder  
25 which decodes the X address signal fetched through the  
address latch AIL. The word driver WDRV drives a word  
line on the basis of the select signal outputted from  
the X address decoder XADEC. In the data read

1 operation, the word driver drives the word line with a  
voltage such as 5 V and in the data write operation, it  
drives the word line with a high voltage such as 12 V.  
In the data erase operation, all the outputs of the word  
5 drivers are set for a low voltage level such as 0 V.

YADEC denotes a Y address decoder for decoding  
the Y address signal fetched through the address latch  
AIL. YSEL denotes a Y selector for selecting the data  
line in accordance with the output select signal of the  
10 Y address decoder YADEC. SA denotes a sense amplifier  
for amplifying the read signal from the data line  
selected by the Y selector YSEL in the data read  
operation. DOL denotes a data output latch for holding  
the output of the sense amplifier SA. DOB denotes a  
15 data output buffer for outputting outside the data held  
by the data output latch DOL.

In Fig. 10, PDB0 to PDB7 denote low order  
eight-bit (one byte) data and PDB8 to PDB15 denote high  
order eight-bit (one byte) data. According to this  
20 embodiment, the output data is maximum two bytes. DIB  
denotes a data input buffer for fetching the write data  
supplied from outside. The data fetched from the data  
input buffer DIB is held by the data input latch DIL.  
When the data held by the data input latch DIL is "0",  
25 the write circuit WR supplies a high voltage for write  
to the data line selected by the Y selector YSEL. This  
high voltage for write is supplied to the drain of the  
memory cell, to the control gate of which a high voltage

1 is applied, in accordance with the X address signal, so  
that this memory cell is written.

EC denotes an erase circuit for simultaneously  
erasing the memory blocks by supplying an erase high  
5 voltage to the source line of the designated memory  
blocks. Designation of the erase blocks for the erase  
circuit EC is made by an erase block designation register  
MBREG. Writing of data in this register MBREG is carried  
out by the CPU10.

10 FCONT denotes a controlling circuit for selec-  
tively controlling the timing of the data readout opera-  
tion in the flash memory FMRY2, various timings for write  
and erase and selection of voltages. The controlling  
circuit FCONT includes an erase block designation  
15 register MBREG and a control register CREG. This con-  
trolling circuit FCONT executes these processings by  
referring to the content of the control register CREG.  
In Fig. 10, the registers MBREG and CREG are shown out-  
side the block of the circuit FCONT for convenience sake.

20 Figs. 12A to 12C show examples of the control  
register CREG and the erase block designation register  
MBREG described above. This erase block designation  
register MBREG comprises two registers MBREG1 and MBREG2,  
and each of the registers MBREG1, MBREG2 is an eight-bit  
25 register. In the control register CREG, Vpp denotes a  
high voltage application flag which is set for "1" for  
application of the high voltage for rewrite. E bit is a  
bit designating the erase operation, and EV bit

1 is a designation bit of a verify operation at the time of  
an erase operation. P bit is a designation bit of the verify  
operation at the time of the write operation (program  
operation), and PV bit is a designation bit of the verify  
5 operation at the time of a write operation. The erase block  
designation registers MBREG1, MBREG2 are the registers  
which designate which of memory blocks contained in the  
large memory blocks divided into the seven blocks and in  
the small memory blocks divided into the eight blocks  
10 should be erased. The bits from the 0th bit to the  
seventh bit are designation bits for each memory block.  
For example, the bit "1" means the selection of the  
corresponding memory block and the bit "0" means non-  
selection of the corresponding memory block. When the  
15 seventh bit of the erase block designation register  
MBREG2 is "1", for example, erase of the small memory  
block SMB7 is designated.

The registers CREG, MBREG1, MBREG2 are made  
readable and writable by the CPU 10.

20 The controlling circuit FCONT refers to the  
set contents of the registers CREG, MBREG1, MBREG2 and  
executes erase and write. The CPU 10 can control the  
erase and write operations by rewriting the contents of  
the registers CREG, MBREG1, MBREG2. When the PROM  
25 writer write mode described already is set, for example,  
the CPU 10 sets the registers CREG, MBREG1, MBREG2 in  
accordance with the contents of the commands written in  
the command latch by the PROM writer 30.

1 In Fig. 10, FLM, MS-FLN, MS-MISN, M2RDN,  
M2WRN, MRDN, NWRN, IOWORDN, RST, VPPH, A9H, SECSN, SECN,  
DSCN and XMON are supplied as the control signals to the  
controlling circuit FCONT.

5 The control signal FLM is the signal which  
designates the operation mode of the flash memory FMRY2,  
and is set for the logic value "1" when the  
microcomputer MCU3 is connected to the PROM writer 30  
and is made rewritable, and for the logic value "0" at  
10 other times. This signal FLM is generated on the basis  
of the mode signals MD0 to MD2 described above, for  
example. The control signal MS-FLN is the select signal  
for selection of the flash memory FMRY2. The control  
signal MS-MISN is the select signal of the registers  
15 CREG, MBREG1, MBREG2. Which of these registers CREG,  
MBREG1, MBREG2 should be selected is decided by the low  
order two bits (PAB0 and PAB1) of the address signal  
outputted from the CPU 10, M2RDN denotes the memory read  
strobe signal, M2WRN denotes the memory write strobe  
20 signal, MRDN denotes the read signal for reading from the  
control register CREG, MWRN denotes the write signal for  
writing in the control register CREG. The memory write  
strobe signal M2WRN is regarded as the strobe signal for  
writing the data, which is to be written in the memory  
25 cells, in the data input latch DIL. The practical write  
operation into the memory cells is started when the P  
bit of the control register CREG is set. The control  
signal IOWORDN denotes a switch signal of the eight-bit

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1 read access and the sixteen-bit read access for the  
flash memory FMRY2. The control signal RST denotes a  
reset signal of the flash memory FMRY2. When this  
signal RST resets the flash memory FMRY2 or when the Vpp  
5 flag of the control register CREG is set for "0", each  
mode setting bit of EV, PV, E and P in the register CREG  
is cleared. VPPH denotes a detection signal indicating  
that Vpp = 12 V is detected. By the way, other signals  
A9H, SECN, DSCN and XMON are enable signals and test  
10 enable signals of the security bits, and since they are  
not directly relevant to the present invention, their  
detailed explanation will be omitted.

[6] Hardware adapted to command system

Fig. 13 shows details of hardware for  
15 facilitating the PROM writer rewrite mode by the command  
system in the microcomputer shown in Fig. 8. The  
hardware are implemented within a single semiconductor  
substrate 1.

The command and the address that are supplied  
20 from the PROM writer 30 are asynchronously inputted with  
respect to the CPU 10. Therefore, the command latch CL  
for receiving the command and the address latch AL for  
receiving the address are provided. The port PORT to be  
connected to the PROM writer 30 is primarily determined  
25 through the socket adapter, not shown in the drawing.  
When the port PORT has a register, the register can be  
used as the address latch AL and the command latch CL,  
and they may not be provided separately. A command flag

40

1 CF is allocated to a predetermined bit of the command  
latch CL so that the CPU 10 can recognize write of the  
command into the command latch CL. When the command  
flag CF is set up, the CPU 10 can know that the command  
5 is inputted to the command latch CL, and then reads the  
command. In the write operation by the PROM 30, the  
write operation of the command is first made and then,  
the address and the data are written in the address  
latch AL and the data latch from the PROM writer 30,  
10 whenever necessary. At this time, since the time from  
the command input to the data input is as short as  
minimum 20 ns, there may be a case where the data is  
inputted to the command latch CL before the CPU 10 reads  
the command. Therefore, to avoid collision between the  
15 command and the data, the data latch DL for receiving  
the data is provided besides the command latch CL.  
Further, a data flag DF representing that the data is  
inputted to the data latch DL is allocated to a  
predetermined bit of the command latch. In the case of  
20 CF = 1 (representing that the command has already been  
inputted) or DF = 1 (representing that the command has  
already been inputted and furthermore, the data has also  
been inputted already), the CPU 10 reads the command,  
and reads the data after recognition of the command in  
25 the case of DF = 1.

Here, the two latches, that is, the command  
latch CL and the data latch DL, share the data  
input/output port PORT. Therefore, the command and the



1 data inputted from the PROGM writer 30 must be  
discriminated. For this reason, the input data from the  
PROM writer 30 is latched in the command latch CL when  
CF = 0 and DF = 0, and is latched in the data latch DL  
5 when CF = 1 and DF = 0. In other words, as shown  
conceptually in Fig. 13, there is provided an AND gate  
AND which receives the signal corresponding to the logic  
values of the write signal WE\*, the command flag CF and  
the data flag DF from the PROM writer 30 and generates  
10 latch control signals.

Further, as shown in Fig. 14, too, this  
embodiment employs the logic such that the kind of the  
command latched by the command latch CL is decoded by  
the decoder DEC, the command flag CF is set when the  
15 command is a predetermined command, and the data flag DF  
is set and moreover, the command flag CF is cleared when  
the data is latched in the data latch DL. In this way,  
the separate use of the command latch CL and the data  
latch DL can be accomplished. According to this  
20 embodiment, the command latch CL is the eight-bit  
register, the low order two bits are the data flag DF  
and the command flag CF and the high order four bits are  
command latch bits. By the way, AIB in Fig. 13 denotes  
an address input buffer and MPX denotes an address  
25 multiplexer.

As described above, the command latched in the  
command latch CL is decoded by the command decoder DEC  
and the command flag CF is set. If this processing is

1 handed over to the CPU 10, the CPU 10 must always  
monitor the content of the command latch CL by activat-  
ing the bus cycle, and in this case, a waste of opera-  
tion takes place. Further, if the CPU 10 must analyze  
5 all the commands of the command latch CL in accordance  
with the set condition of the command flag CF which is  
controlled by the command decoder DEC, the timing of the  
operation designated by the command may be too late. An  
example is the read command which reads out the data  
10 from the flash memory FMRY2. To cope with this problem,  
there is provided, inside the internal buses ABUS, DBUS,  
bus switches BSW1 and BSW2 capable of selectively  
establishing a state where the command latch CL, the  
data latch DL and the address latch AL are connected to  
15 the flash memory FMRY2 and a state where the command  
latch CL, the data latch DL and the address latch AL are  
not connected to the flash memory FMRY2 as shown in  
Figs. 13 and 14, and these bus switches BSW1 and BSW2  
are controlled by the signal obtained by the decoding  
20 result of the read type commands by the decoder DEC.  
When the bus switches BSW1 and BSW2 are opened, a direct  
read access can be made to the flash memory from outside  
the microcomputer MCU3 or in other words, from the PROM  
writer 30.

25 [7] Command specification data write and others in a  
flash memory by PROM writer

Table 3 shows examples of the command specifi-  
cation which may be supplied from the PROM writer 30.

Table 3

COMMAND	CYCLE NUMBER	1ST CYCLE			2ND CYCLE		
		MODE	ADDRESS	DATA	MODE	ADDRESS	DATA
READ	2	WRITE	X	00H	READ	RA	DOUT
READ ID	2	WRITE	X	90H	READ	IA	ID
ERASE	2	WRITE	X	20H	WRITE	X	20H
E VERIFY	2	WRITE	X	A0H	READ	X	EVD
A ERASE	2	WRITE	EA	30H	WRITE	X	30H
PROGRAM	2	WRITE	X	40H	WRITE	PA	PD
P VERIFY	2	WRITE	X	COH	READ	X	PVD
RESET	2	WRITE	X	FFH	WRITE	X	FFH

- 1 The commands shown in the table are eight kinds, though this number is not particularly limited. The content of the cycle to be activated by the PROM writer 30 in response to each command is also shown. The code of the
- 5 command corresponds to the data of the first cycle shown in the table. This code is represented by the hexadecimal number and symbol H put at the end of the code means the hexadecimal number. The read command (Read) is the command for reading out the data from the flash
- 10 memory FMRY2. Symbol RA in the second cycle of this command means the read address. The read ID command (Read ID) is the command for reading out a product identification code (ID) from a product identification code address (IA). The erase command (Erase) is the
- 15 command for erasing the data of the flash memory. To avoid over-erase (the phenomenon in which Vth of the

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1 memory becomes negative due to excessive erase and  
normal read-out cannot be made) during erasing, pre-  
write is executed for making a write level uniform before  
beginning the erasing operation, or an erase procedure  
5 which effects erasure little by little while effecting  
verify is employed. The erase verify command (E Verify)  
is the command for confirming the erase condition. EA  
represents the memory address for erase verify. EVD  
represents the erase verify output data. The automatic  
10 erase mode (A Erase) is the command for automatically  
executing erase and erase verify, and after the  
automatic erase is started, the end of this automatic  
erasing operation is confirmed by a status polling. A  
status polling flag SPF is allocated to the high order  
15 side bit of the data latch DL shown in Fig. 13. The  
write command (Program) is the command for designating  
write, PA represents the write address and PD represents  
the write data. A program verify command (P Verify) is  
the command for confirming whether or not the data  
20 written immediately before is written correctly, and PVD  
represents a program verify output data. A reset  
command (Reset) is the command for resetting the command  
when this command is mistaken.

The command specification described above has  
25 compatibility with the command specification of discrete  
flash memory LSIs (1M-bit flash memory) of an HN28F101  
series described on page 872 of "Hitachi IC Memory Data

45

1 Book 1" published in September, 1991, though the  
specification is not particularly limited.

[8] Data write in a flash memory in on-board state

The designation of the data write in the on-  
5 board state and its sequence are all controlled by the  
CPU 10 and its operation program, and processing such as  
data write is controlled by setting/clearing each bit of  
the control register CREG by the software. When the  
rewrite program is placed on the flash memory FMRY2, for  
10 example, the rewrite program is in advance transferred  
to the RAM at the time of the data write operation or at  
the time of resetting of the system, and the CPU 10  
executes this program on the RAM so as to execute data  
rewrite. An example of the sequence of this rewrite  
15 processing will be hereinafter described in this item.

The data write in the flash memory is  
basically effected to the memory cells in an erase  
state. When rewrite of the flash memory included in the  
microcomputer is carried out in a state where the  
20 microcomputer is mounted onto the system, the rewrite  
control program to be executed by the CPU 10 includes  
the erase program and the write program. This rewrite  
control program can be constituted in such a manner that  
the erase processing routine is first executed and then  
25 the automatic write processing routine is successively  
executed in accordance with the data write instruction.  
Alternatively, the erase operation and the write  
operation may be separately designated.

1 Figs. 15A and 15B show a detailed example of  
the write control procedure. The control main body of  
the procedure shown in the drawings is the CPU 10.

In the first step of writing data in the byte  
5 unit, the CPU 10 sets 1 to its built-in counter n (Step  
S1). Next, the CPU 10 sets the data to be written in  
the flash memory FMRY2, in the data input latch DIL  
shown in Fig. 13 and sets the write address in the  
address latch AIL (Step S2). Then, the CPU 10 issues  
10 the write cycle for the control register CREG and sets  
the program bit P (Step S3). The controlling circuit  
FCONT applies a high voltage to the control gate and the  
drain of the memory cell designated by the address on  
the basis of the data and the address that are set in  
15 the Step S2, and executes write. The CPU 10 is in the  
waiting state for the time (x)  $\mu$ sec as the write  
processing time on the flash memory side (Step S4), and  
then clears the program bit P (Step S5). Here, the time  
(x)  $\mu$ sec is determined in accordance with the character-  
20 istics of the memory cell and is 10  $\mu$ sec, for example.

Thereafter, the CPU 10 issues the write cycle  
for the control register CREG to confirm the write state  
and sets the program verify bit PV (Step S6). The  
controlling circuit FCONT utilizes the address set by  
25 the Step S2, applies the verify voltage to the word line  
to be selected by the address and reads out the data of  
the memory cell which is written as described above.  
CPU 10 waits for (y)  $\mu$ sec for this data read out (Step

1 S7). Here, to insure a sufficient write level, the  
verify voltage is at a voltage level of 7 V higher than  
the power source voltage of 5 V, for example. The time  
(y)  $\mu$ sec is determined by the rise characteristics of  
5 such a verify power source, and is below 2  $\mu$ sec, for  
example. The CPU 10 confirms coincidence between the  
data thus read out and the data used for write (Step  
S8). When the CPU 10 confirms this coincidence by  
verify, it clears the program verify bit PV (Step S9)  
10 and in this way, the write operation of this one-byte  
data is completed.

On the other hand, when the CPU 10 confirms  
inequality by verify in the Step S8, it clears the  
program verify bit PV in the Step S10, and then judges  
15 whether or not the value of the counter n reaches the  
upper limit number N of the write re-try (Step S11).  
When this upper limit number N of the write re-try is  
reached, the processing is completed as write fault.  
When the upper limit number N is not reached, the CPU 10  
20 increments by one the value of the counter n (Step S12),  
and repeats the processing from the Step S3 described  
above.

Figs. 16A and 16B show a detailed example of  
the erase control procedure. The control main body of  
25 the procedure shown in the drawings is the CPU 10.

To effect erase, the CPU 10 sets 1 in its  
built-in counter n (Step S21). Next, the CPU 10  
executes pre-write in the memory cells in the region to

1 be erased (Step S22). In other words, the CPU 10 writes  
the data "0" in the memory cell of the address where  
erase is to be effected. The control procedure of this  
pre-write can use the write control procedure explained  
5 with reference to Figs. 15A and 15B. This pre-write  
processing is made so as to make uniform the charge  
quantity inside the floating gate before erase  
throughout all the bits to thereby make uniform the  
erase state of each memory cell to be erased.

10 Next, the CPU 10 issues the write cycle for  
the erase block designation registers MBREG and  
designates the memory blocks as the simultaneous erase  
object (Step S23). In other words, the CPU 10  
designates the number of memory blocks to be erased to  
15 the erase block designation registers MBREG1 and MBREG2.  
After the memory blocks to be erased are designated, the  
CPU 10 issues the write cycle for the control register  
CREG and sets the erase bit E (Step S24). The  
controlling circuit FCONT applies the high voltage to  
20 the source line of the memory blocks designated in the  
Step S23 and simultaneously erases the memory blocks.  
The CPU 10 waits for the time of (x) msec (Step S25).  
Here, the time (x) msec is determined to match with the  
characteristics of the memory cell transistors, and is  
25 10 msec, for example. This time (x) msec is shorter  
than the time in which the erase operation can once be  
completed. Next, the erase bit E is cleared (Step S26).

Next, to confirm the erase condition, the CPU



1 10 sets the leading addresses of the memory blocks to be  
simultaneously erased for the address to be verified  
(Step S27), and then executes dummy write to the verify  
address (Step S28). In other words, the CPU 10 issues  
5 the memory write cycle to the address to be verified.  
In consequence, the memory address to be verified is  
latched in the address latch AIL. Thereafter, the CPU  
10 issues the write cycle for the control register CREG  
and sets the erase verify bit EV (Step S29). Utilizing  
10 the address set in the Step S28, the controlling circuit  
FCONT applies the erase verify voltage to the word line  
to be selected and reads out the data of the memory cell  
which is to have been erased as described above. To  
read the data, the CPU 10 waits for time (y)  $\mu$ sec (Step  
15 S30). To insure a sufficient erase level, the erase  
verify voltage is set for a voltage level of 3.5 V, for  
example, which is lower than the power source voltage  
Vcc such as 5 V, for example. The time (y)  $\mu$ sec is  
determined by the rise characteristics of the verify  
20 power source and is the time of shorter than 2  $\mu$ sec, for  
example. The CPU 10 verifies whether or not the data  
read by it coincides with the data under the erase  
completion state (all "1" bit state) (Step S31). After  
confirming the coincidence by this verify, the CPU 10  
25 clears the erase verify bit EV (Step S32). Next,  
whether or not the verify address of this time coincides  
with the final address of the erased memory block is  
judged (Step S33), and if it is, the series of the erase

1 operation is completed. When it is not judged as  
reaching the final address, the verify address is  
incremented by one (Step S34), and the processing from  
the Step S28 is again repeated.

5 On the other hand, when the CPU 10 confirms  
inequality by the verify operation in the Step S31, it  
clears the erase verify bit EV in the Step S35 and then  
judges whether or not the value of the counter n has reached  
progressively the upper limit number N of erase (Step  
10 S36). If this upper limit number N is reached, the  
processing is completed as an erase fault. If the upper  
limit number N is not reached, the CPU 10 increments the  
value of the counter by one (Step S37) and repeats the  
processing from the Step S24. In order to prevent over-  
15 erase in which the threshold voltage of the memory cell  
becomes negative, erase is gradually repeated in  
practice every time within a short time such as 10 msec  
by effecting verify each time.

#### [9] Data write operation by command system

20 When the data write mode by the PROM writer is  
set in the microcomputer MCU3 through the mode signals  
MDO to MD2, the data is written in the flash memory  
FMRY2 by the PROM writer 30 by the system referred to as  
the "command system". Here, the term "command system"  
25 means a system in which a command such as for data writing  
in the flash memory is given by such command from an  
external device such as the PROM writer 30. The CPU 10  
controls the processing based on the command. The

51

1 control program for this purpose is stored in the flash  
memory FMRY2, and this program is transferred to the RAM  
in response to setting of the data write mode by the  
PROM writer 30. The CPU 10 executes the control program  
5 thus transferred to the RAM. This control program may  
be partly in common to the program for controlling the  
data write in the built-in flash memory in the on-board  
state described already, or may be entirely different.  
The command specification has already been explained  
10 with reference to Table 3. Hereinafter, the operation  
will be explained for each command.

(1) Write command (PROGRAM)

The PROM writer 30 writes, asynchronously with  
respect to the CPU 10, the command, the data and the  
15 address in the command latch CL, the data latch DL and  
the address latch AL shown in Fig. 13, respectively, in  
accordance with the command specification shown in Table  
3. When the command flag CF is CF = 1 (the command has  
already been inputted) or when the data flag DF is DF =  
20 1 (the command has been inputted and further, the data  
has been inputted), the CPU 10 reads the command, and  
when the data flag is DF = 1 after recognition of the  
command, it reads the data and the address. The command  
supplied from the PROM writer 30 is latched in the  
25 command latch CL in accordance with the command flag CF  
= 0 and the data flag DF = 0. The data to be written in  
the memory cell is latched in the data latch DL in  
accordance with the command flag CF = 1 and the data

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1 flag DF = 0. After recognizing that the command, which  
is read, is the "write command", the CPU 10 reads the  
address and the data from the address latch AL and the  
data latch DL, respectively, and transfers them to the  
5 address input latch AIL and the data input latch DIL  
inside the flash memory FMRY2, respectively, according  
to their control programs. The CPU 10 practically  
executes write in the memory cell of the flash memory  
FMRY2 by setting the write bit (P bit) of the control  
10 register CREG. The procedure for the practical write  
processing into the memory cell is substantially the  
same as the procedure which has been explained with  
reference to Figs. 15A and 15B. After the write  
operation is made, the P bit is cleared, and CF and DF  
15 are returned to 0. Fig. 17 altogether shows states of  
the flags CF and DF in the write operation as well as  
the operation of the CPU 10.

(2) Write verify command (P VERIFY)

After the write operation is completed, the  
20 write verify mode is essentially executed. This write  
verify is the operation which confirms whether or not  
the data written immediately before is certainly  
written. In the case of this command, too, the  
operation up to the analysis of the command is executed  
25 in the same way as in the write command described above.  
After confirming that the command is the write verify  
command, the CPU 10 effects the control in accordance  
with the following procedure. First, the CPU 10 sets

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1 the PV bit (program verify bit) of the control register  
CREG to "1". At this time, the address used for the  
write operation immediately before is latched in the  
address latch AIL inside the flash memory FMRY2.  
5 Accordingly, the verify voltage (such as 7 V) is applied  
to the word line selected by this address. Next, the  
CPU 10 reads the flash memory FMRY2. In this case, too,  
the latched address is used as the address. After all,  
the read operation is executed in the state where the  
10 verify voltage is applied as the gate voltage to the  
memory cell in which write is previously made. The CPU  
10 writes this read data in the data latch DL of the  
port PORT, clears the PV bit and completes the  
operation. The PROM writer 30 executes verify by reading  
15 the value of the data latch DL. Fig. 18 altogether  
shows states of the flags at the time of verify and the  
operation of the CPU 10 at this time.

### (3) Erase command (ERASE)

In the microcomputer MCU3 according to this  
20 embodiment, the erase operation of the built-in flash  
memory FMRY2 in the microcomputer MCU3 does not support  
block erase but only simultaneous erase of a memory cell  
array (one of ARY0, ARY1, shown in Fig. 3, for example)  
so that the built-in flash memory is compatible with a 1  
25 M flash memory (HN28F101) in the form of a discrete  
flash memory LSI described already. As is obvious from  
the command specification shown in Table 3, the erase  
operation is started when the erase command is written

54

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1 twice. In the case of erase, too, the operation up to  
the command analysis is the same as that of the write  
operation. This erase is started by setting all the  
bits of the erase block designation registers MBREG1 and  
5 MBREG2 for a select state and then setting the E bit  
(erase bit) of the control register CREG for "1". When  
the E bit is set, the high voltage is applied to the  
memory cell array and erase is carried out. After the E  
bit is set for "1" for a predetermined time, it is  
10 cleared and erase is completed. The control procedure  
of erase of the memory cell is substantially the same as  
the control content explained with reference to Figs.  
16A and 16B.

(4) Erase verify command (E VERIFY)

15 The verify operation which is executed after  
erase is similar to the write verify operation. After  
the command analysis, the CPU 10 reads the address to be  
verified from the address latch AL of the port and  
writes it in the flash memory FMRY2. Next, the CPU 10  
20 sets the EV bit of the control register CREG, so that  
the verify voltage (such as 3.5 V) is applied to the  
word line selected by the address latched previously.  
The CPU 10 reads the flash memory FMRY2 in this state,  
and writes the read data to the data latch DL of the  
25 port. Thereafter, the EV bit is cleared and the verify  
operation is completed.

(5) Automatic erase command (A ERASE)

After recognizing the automatic erase command,

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1 the CPU 10 executes by itself all the erase flows shown  
in Figs. 16A and 16B. In this automatic erase, the  
flash memory FMRY2 outputs the status polling signal  
simultaneously with the start of erase, and inverses the  
5 signal upon completion of erase. Since the output of  
the status polling is ED7 (Fig. 8), the seventh bit of  
the data latch DL (Fig. 13) is used as the bit for  
storing the status polling signal. The CPU 10 clears the  
seventh bit (the most significant bit) of the data latch  
10 DL simultaneously with the start of erase, and sets upon  
completion of erase.

(6) Read command (READ)

When the read command (read type command) is  
issued, the flash memory FMRY2 must be brought into a  
15 state where it can be freely read from the PROM writer  
30. When the CPU 10 interprets the command, the time  
from the input of the command till the point at which  
the command becomes readable becomes extended and cannot  
match with the specification of the 1M flash memory.  
20 Therefore, the CPU 10 is cut off by the bus switches  
BSW1 and BSW2 (Fig. 13) in the read mode, and a direct  
access is permitted from outside to the built-in flash  
memory FMRY2. The CPU 10 is allowed to input a BREQ  
(bus request) signal for requesting bus privilege to  
25 open from outside, but the bus switches BSW1 and BSW2  
physically cut off the bus because a long time is  
necessary before the CPU 10 opens the bus. Since a long

56

1 time is necessary if all the commands are passed through  
the CPU 10, the CPU 10 is instantaneously cut off as  
soon as the decoder DEC (Fig. 13) recognizes the  
commands as the read commands. In this case, in order  
5 to prevent the CPU 10 from recognizing the input of the  
command, the command flag CF is kept as  $CF = 0$  in the  
case of the read command, and the command flag  $CF = 0$  is  
changed to the command flag  $CF = 1$  only in the case of  
the other commands.

10 (7) Reset command (RESET)

The reset command is prepared to cope with the  
case where setup of the command is mistaken. As is  
obvious from the command specification shown in Table 3,  
reset is completed when this reset command is written  
15 twice. If any command is inputted at first and then the  
command is again inputted in the microcomputer MCU3  
according to this embodiment, the command is inputted to  
the data latch DL. Therefore, there is a possibility  
that the reset command first written is recognized as  
20 the data FFH. However, since the flash memory regards  
the erase state, where the electrons are extracted from  
the floating gate, as "1", FFH becomes equal to the  
state where nothing is written, even though the write  
command has been inputted beforehand, and there is no  
25 problem at all. When the reset command written at the  
second time is decoded by the command decoder DEC, the  
mode is brought into the read state as such in the same  
way as in the read mode, and the operation is completed.



1 Figs. 19A and 19B altogether show states of the flags in  
such a reset state and the operation of the CPU 10.

[10] Operation of PROM writer 30 for data write by  
command system

5 Figs. 20A and 20B show the operation flow  
charts of the PROM writer 30 during the data write  
operation. First, the high voltage necessary for write,  
such as 12 V, is applied to the terminal Vpp (Fig. 8)  
(Step S40) so as to initialize the built-in address  
10 counter to 0 (Step S41) and to set the counter n for 0  
(Step S42). Next, the counter n is incremented by one  
(Step S43), and then the write cycle of the program is  
activated so as to write the write command (40H) into  
the command latch CL (Step S44). The write data (PD)  
15 and the write address are written into the data latch DL  
and the address latch AL, respectively (Step S45).  
Thereafter, the PROM writer waits for a time of 25  $\mu$ sec,  
for example (Step S46). In the interim, the CPU 10 of  
the microcomputer interprets the command and writes the  
20 data in the flash memory FMRY2. The write cycle of the  
write verify command is activated this time (Step S47),  
and the PROM writer 30 waits for a time of 6  $\mu$ sec, for  
example (Step S48). In the interim, the CPU 10 of the  
microcomputer MCU 3 interprets this command and reads  
25 out the data of the write address in the data latch DL.  
The PROM writer 30 takes in this read data and judges  
whether or not write can be effected normally (Step  
S49). When the result of judgement proves normal,

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1 whether or not it is the last write address is judged  
(Step S50). If it is not the last address, the write  
address is incremented (Step S51) and the flow then  
returns to the Step S42. After write is made to the  
5 last address, the high voltage Vcc such as 5 V is  
applied to the terminal Vpp (Step S52) and write is  
completed. When any write abnormality is judged in the  
Step S49, the flow returns again to the Step S43 and  
write is repeated until the value of the counter n  
10 reaches maximum 20, for example. If this write ab-  
normality cannot be solved even after this write opera-  
tion is repeated twenty times, the processing is com-  
pleted by regarding this address as the defective bit.

Figs. 21A and 21B show the operation flow  
15 charts of the PROM writer 30 during the erase operation.  
First, the data of the logic value 0 is written in all  
the erase object bits of the flash memory. The write pro-  
cessing is made in accordance with the flowcharts shown in  
Figs. 20A and 20B. Next, the leading address of the  
20 erase region is set in the address counter (Step S61)  
and the counter n is set for 0 (Step S62). Next, the  
counter n is incremented by one (Step S63) and then the  
erase command (20H) is written in the command latch CL  
by activating the write cycle of the erase command (Step  
25 S64). Thereafter, the PROM writer 30 waits for a time  
of 10 msec, for example (Step S65). In the interim, the  
CPU 10 of the microcomputer MCU3 interprets the command  
and erases the flash memory FMRY2. The write cycle of

59

1 the erase verify command is activated this time (Step  
S66) and the PROM writer 30 waits for a time of 6  $\mu$ sec,  
for example (Step S67). In the interim, the CPU 10 of  
the microcomputer MCU3 interprets the command, reads out  
5 the data from the erase verify address (EA) and transfers  
the data to the data latch DL. The PROM writer 30 inputs  
this read data and judges whether or not erase can be  
effected normally (Step S68). When the result of judgement  
proves normal, a judgement is effected as to whether or not the  
10 present erase verify address is the last address (Step S69). If  
it is not the last address, the erase verify address is incre-  
mented (Step S70) and then the flow returns to the Step S66.  
Erase verify is then carried out until the last address  
and the processing is completed. If erase abnormality  
15 is judged in the Step S68, the flow returns again to the  
Step S63 and erase is repeated until the value of the  
counter n reaches maximum 3,000, for example. When this  
erase abnormality cannot yet be solved even after  
repetition of 3,000 times, the processing is completed  
20 by regarding the address as the defective bit.

[11] Operation of CPU for data write by command system

Fig. 22 shows a main flowchart of the  
processing by the CPU 10 for various commands described  
above. The CPU 10 performs polling of the command flag  
25 CF and the data flag DF, and upon detecting their set  
state, the CPU 10 reads the high order four bits of the  
command latch CL (Fig. 14) and analyzes the command.

1 The processing routine branches to Erase Verify when the  
command is A0H, to Write Verify (Program Verify) when it  
is C0H, to write (Program) when it is 40H, to erase when  
it is 20H, and to automatic erase (Auto Erase) when it  
5 is 30H. By the way, the explanation of other commands  
explained with reference to Table 3 will be omitted.

In the processing routine of Erase, the  
sequence necessary for erasing the flash memory is  
controlled as shown in Fig. 23A, the command flag CF is  
10 cleared and then the processing is completed.

In the processing routine of Erase Verify  
shown in Fig. 23B, the erase verify address is fetched  
from the address latch AL, the erase verify mode is set  
in the control register CREG, and the data from this  
15 address is read and transferred to the data latch DL.

In the processing routine of Automatic Erase,  
control of pre-write execution is made for all the  
addresses of the built-in flash memory FMRY2 (to be  
subjected to erase) as shown in Fig. 24, erase control  
20 is then made, and erase verify is executed. Control of  
erase and erase verify is made till completion of erase  
of all the addresses (to be subjected to erase). When  
erase abnormality repeatedly occurs and exceeds the  
upper limit of the erase time in the judgement of the  
25 erase condition, the processing is completed with the  
existence of the defective bit.

In the processing routine of Program, the set  
state of the data flag DF is judged as shown in Fig.



1 obtained. The result of the investigation is shown in Table 4. It has been confirmed from the result of the investigation that compatibility can be obtained at an operation frequency of 16 MHz, for example.

Table 4

Response time from write of command in command latch to start of actual operation responsive to the written command

ITEM	ERASE VERIFY	WRITE VERIFY	ERASE	WRITE
RESPONSE TIME BY SOFTWARE CONTROL (OPERATION FREQUENCY: 16 MHz) ACCORDING TO EMBODIMENT	4.7 $\mu$ s	4.8 $\mu$ s	5.9 $\mu$ s	5.7 $\mu$ s
RESPONSE TIME REQUIRED FOR 1M FLASH MEMORY COMPATIBLE SPECIFICATION	5 $\mu$ s OR LESS	5 $\mu$ s OR LESS	1 ms OR LESS	10 $\mu$ s OR LESS
JUDGEMENT	○	○	○	○

5 The embodiments described above provide the following functional effects.

(1) The rewrite sequence in accordance with the commands asynchronously given from the PROM writer 30 is accomplished by the built-in circuit of the  
10 microcomputer. Therefore, it is only necessary for the PROM writer 30 to write the commands in the command

1 latch in the same way as it gives the data, before the  
data and the address data are given. Accordingly, data  
writing can be effected in the flash memory built-in in the  
microcomputer by connecting the PROM writer 30, which is  
5 used widely, through the socket adapter.

(2) The built-in CPU 10 is caused to control the  
rewrite sequence given by the commands. Therefore, the  
exclusive circuit for only this control can be  
eliminated or the number of such circuits can be  
10 reduced, and the chip area of the microcomputer can be  
reduced. Furthermore, the control sequence for rewrite  
can be changed by the software which the CPU 10 should  
execute. Accordingly, setting of the conditions such as  
the write time can be easily effected so as to match with  
15 the characteristics of the memory devices constituting the  
flash memory.

(3) The PROM writer 30 versatily utilized is so  
constituted as to apply at least the high voltage for  
rewrite for the nonvolatile memory device and to supply  
20 the address and the data for rewrite in accordance with  
the write signal, etc, to the object semiconductor  
device (LSI) inclusive of the flash memory. Such a PROM  
writer 30 supplies, asynchronously with the CPU 10  
built-in in the microcomputer, the commands, the data  
25 and the addresses. At this time, there are provided the  
command flag CF representing that the command is written  
in the command latch CL, and the data latch DL which is  
made writable from outside in addition to the command

1 latch CL when this command flag CF represents the  
command latch state. In this way, collision can be  
prevented between the commands and the data that are  
written from the PROM writer 30 in mutually different  
5 cycles, on the latch means.

(4) The CPU 10 reads the command of the command  
latch on the basis of the command latch state of the  
command flag CF. At this time, the set processing of  
the command flag can be speeded up because there is  
10 provided the command decoder for decoding the latch  
content of the command latch CL and setting the command  
flag CF for the command latch state. If the control for  
the command flag is also assigned to the CPU 10, the CPU  
10 must activate the bus cycle and must always monitor  
15 the content of the command latch CL, so that a wasteful  
operation undesirably occurs and the flag processing  
becomes delayed, as well.

(5) The present invention provides the bus  
switches BSW1 and BSW2 which cut off the CPU 10 from the  
20 flash memory in accordance with the decoding result of  
the read commands by the command decoder DEC. If the  
CPU 10 were to analyze all the commands latched in the  
command latch, the timing of the operation designated by  
the command would be retarded. However, the present  
25 invention can easily cope with the read commands due to  
the bus switches. This makes it possible to accomplish  
compatibility, with respect to the write processing,  
between the discrete flash memory LSI and the flash



1 memory built-in in the microcomputer, as seen from the  
PROM writer 30.

(6) The program for controlling the rewrite  
procedure of the flash memory, which is to be executed  
5 by the CPU 10, is stored in the flash memory and is  
transferred to the RAM in response to setting of the  
rewrite mode by the PROM writer 30. The CPU 10 executes  
this program transferred to the RAM and, in this way,  
correction of the rewrite program can be made.

10 (7) In view of the fact that the quantity of data  
to be stored in the flash memory becomes different  
depending on the usage of the data and on the kind of  
data employed such as the program, the data table, the  
control data and so forth, a plurality of memory blocks  
15 having mutually different memory capacities are provided  
as a simultaneously erasable unit in the flash memory  
and in this way, a waste in the write operation caused  
by simultaneous erase of the memory blocks for local or  
partial rewrite of the data held in the built-in flash  
20 memory after mounting onto the system can be eliminated  
to improve the rewrite efficiency.

Although the invention has thus been described  
specifically on the basis of the embodiments thereof,  
the invention is not particularly limited thereto but  
25 can of course be effected via other embodiments and/or  
various modifications thereof including with respect to  
thus far disclosed embodiments and schemes without depart-  
ing from the scope thereof.

For example, the peripheral circuits built-in  
the microcomputer are not limited to those of the

1 embodiments described above, but can be suitably  
changed. The memory cell transistors of the flash  
memory are not limited to the stacked gate structure MOS  
transistors of the embodiments described above, and  
5 FLOTOX type memory cell transistors utilizing the tunnel  
phenomenon for the write operation may be employed.

Besides the memory blocks sharing the source  
line in common, those memory blocks which can share the  
word line in erase can be used as the unit of  
10 simultaneous erase. Which of them is to be used is  
determined by considering the polarity of the erase  
voltage or by considering which of the number of memory  
cells to be connected to a single word line and the  
number of memory cells to be connected to a single data  
15 line is smaller when the memory capacity of the  
simultaneous erase unit is minimized.

The size of the memory blocks is not limited  
to the fixed size as in the embodiments described above.  
For example, the size can be made variable in accordance  
20 with setting of the control register or with designation  
of the mode signal. When the simultaneous erase voltage  
is applied to the word line as being the minimum unit,  
for example, the operation of the driver for driving the  
word line by the erase voltage may be selected in  
25 accordance with setting of the control register or with  
the designation of the mode signal.

Further, the mode of division of the memory  
block may be such that an entire block is first divided

1 into a plurality of large blocks, and then each of the  
large blocks is divided into a plurality of small blocks  
so that simultaneous erase can be made in the unit of  
the large block or small block.

5 In the system which rewrites the flash memory  
under the control of the CPU, a software for self tuning  
the rewrite conditions, etc, can also be employed.

In each memory cell transistor of the flash  
memory, the source and the drain are relatively  
10 recognized in accordance with voltages applied thereto.

The present invention can widely be applied  
to, other than a microcomputer, a data processing  
apparatus having at least a central processing unit and  
an electrically erasable and rewritable nonvolatile  
15 flash memory on a single semiconductor chip.